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FORM PTO-1 (Modified)	449		U.S. Depar Patent and	tment of Commerce Trademark Office	Attorney Docket No.: 1	NICHIA-00700	SO2910/	463	643
INFO	ORMATIO	N-DISCLOSURE S' (Use Several Sheets		PLICANT	Applicant: Shuji Nakan	nura <i>et al</i> .			
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Examiner Initials		Serial / Patent Number	Issue Date	Applic	ant / Patentee	Class	Subclass	Filing	Date
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		Document	Document Publication Date Country / Patent Office		/ Potent Office	Class	Subclass	Trans	lation
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<u></u>	r	OTHER	DOCUMENTS (Inclu	iding Author, Title, D	Date, Relevant Pages, Place	of Publication)			
	AP					.			
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Sheet 1 of 11

FORM PTO-1449 (Modified)

U.S. Department of Commerce Patent and Trademark Office

Attorney Docket No.: NICHIA-00700

Serial No.:09/463643

Applicant: Shuji Nakamura, et al.

Filing Date: January 25, 2000

Group Art Unit:

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(37 CFR § 1.98(b))

aminer		Serial / Patent	Issue Date	Applicant / Patentee	Class	Subclass	Filing Date
ials		Number					
Brob	AA	3566215	2/23/71	Heywang	317	235	7/31/68
	AB	3593191	7/13/71	Henker	331	94.5	9/24/69
7	AC	3655439	4/11/72	Seiter	117	212	6/16/69
	AD	3658585	4/25/72	Folkmann, et al.	117	201	2/26/70
	AE	3704427	11/28/72	Heywang	331	94.5	6/3/64
	AF	3705567	12/12/72	Emels	118	49	1/22/71
	AG	3737737	6/5/73	Heywang, et al.	317	234.R	10/6/71
	АН	3747559	7/24/73	Dietze	118	48	5/15/72
1	AI	3793984	2/26/74	Kasper, et al.	118	48	11/13/72
;	AJ	3819974	6/25/74	Stevenson, et al.	313	499	3/12/73
	AK	3853974	12/10/74	Reuschel, et al.	264	81	2/21/73
	AL	3941647	3/2/76	Druminski	156	612	3/8/73
	AM	3948693	4/6/76	Weyrich, et al.	148	171	7/23/74
	AN	3963537	6/15/76	Kniepkamp, et al.	148	175	8/27/74
	AO	3965347	6/22/76	Heywang	250	211.J	11/12/74
	AP	3974561	8/17/76	Schnoeller	29	611	5/30/74
	AQ	4020791	5/3/77	Reuschel, et al.	118	49.1	11/19/74
ĺ	AR	4062035	12/6/77	Winstel	357	17	1/28/77
1	AS	4098223	7/4/78	Ertl, et al.	118	48	11/4/76
Ĭ	АТ	4102298	7/25/78	Dietze, et al.	118	5	6/10/76
	AU	4108539	8/22/78	Gort, et al.	350	201	11/18/76
	AV	4113381	9/12/78	Epstein	356	5	11/18/76
	AW	4133702	1/9/79	Krimmel	148	1.5	8/11/77
1	AX	4140546	2/20/79	Krimmel	148	1.5	8/17/77
	AY	4154625	5/15/79	Golovchenko et al.	148	1.5	11/16/77
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T I	BA	4261770	4/14/81	Splittgerber, et al.	. 148	171	3/13/80
	вв	4351695	9/28/82	Hieber, et al.	156	603	1/2/81
W	BC	4404265	9/13/83	Manasevit	428	689	4/7/78
1)	BD	4410993	10/18/83	Zschauer	372	44	4/17/81
- 1	BE	4423349	12/27/83	Nakajima, et al.	313	487	7/1/81
V	BF	4505765	3/19/85	Trommer	148	171	6/17/83
BAM	BG	4521448	6/4/85	Sasaki	427	88	3/3/83

Examiner:

Date Considered:

EXAMINER:

Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Sheet 2 of 11 FORM PTO-1449 U.S. Department of Commerce Attorney Docket No.: NICHIA-00700 Serial No.:09/463643 (Modified) Patent and Trademark Office Applicant: Shuji Nakamura, et al. INFORMATION DISCIPLE STATEMENT BY APPLICANT Group Art Unit: Filing Date: January 25, 2000 вн 2/16/83 4531142 7/23/85 Weyrich, et al. 357 17 ВΙ 384 530 12/3/84 4568206 2/4/86 Imazaike ВJ 4596998 6/24/86 Krimmel 357 17 7/19/84 вк 4599244 7/8/86 427 74 9/12/84 Falckenberg, et al. ВL 74 9/11/84 427 4599245 -7/8/86 Falckenberg, et al. вм 4604637 8/5/86 Ruhle, et al. 357 17 3/1/83 BN 4615766 156 662 2/27/85 10/7/86 Jackson, et al. во 4/7/87 372 50 12/23/85 4656636 Amann, et al. ΒP 148 171 6/6/85 4661175 4/28/87 Kuphal, et al. BQ 156 649 4/21/86 4670093 6/2/87 Maerz, et al. BR 4682337 7/21/87 Amann 372 44 9/13/85 BS 9/12/85 4683574 7/28/87 Heinen 372 44 BT 372 44 9/6/85 Wolf 4722088 1/26/88 ВU 156 234 9/15/86 4740259 4/26/88 Heinen ΒV 4742525 5/3/88 372 44 9/6/85 Heinen, et al. BW 372 3/13/87 4744088 5/10/88 Heinen, et al. 50 вх 350 320 3/13/85 4746195 5/24/88 Auracher, et al. ΒY 350 96.20 9/23/86 4763979 8/16/88 Heywang BZ4768199 8/30/88 Heinen, et al. 372 36 9/5/86 CA 350 4/1/87 4792200 12/20/88 Amann, et al. 96.12 СВ 12/20/88 372 46 1/30/87 4792959 Mueller, et al. CC 437 4/4/89 129 5/26/87 4818722 Heinen CD 10/1/87 4829188 5/9/89 Shinomiya, et al. 250 483.1 CE 4835575 5/30/89 Plihal 357 30 2/3/88 CF 357 4841344 6/20/89 Heinen 17 12/7/87 CG 372 38 2/22/88 4845723 7/4/89 Heinen, et al. СН 423 301 4/12/88 4855118 8/8/89 Ichinose, et al. CI 313 3/2/88 4859903 8/22/89 Minematu, et al. 487 СJ 357 17 7/5/88 4864369 9/5/89 Snyder, et al. CK 350 96.12 9/29/88 4869568 9/26/89 Schimpe CL313 6/28/88 12/26/89 487 4890033 Ichinomiya, et al. CM 437 8/25/88 4904617 2/27/90 Muschke 129 437 CN 4904618 2/27/90 Neumark 150 8/22/88 СО 4907044 357 17 7/14/89 3/6/90 Schellhorn, et al. \mathbf{G}^{M} СP 4907534 3/13/90 Huang, et al. 118 725 12/9/88 118 719 1/26/88 4911102 3/27/90 Manabe, et al. Date Considered: SHAM Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next EXAMINER: communication to applicant.

(Modified) INFORMATION DESCRIPTION OF STATEMENT (37 CFR § 1.98(b)) CR 4918497 4/1 CS 4929907 5/2 CT 4944837 7/3 CU 4945394 7/3 CV 4946547 8/	.S. Department of Patent and Tradem NT BY APPLICA 7/90 Edmo	ANT ANT Filing Date:	ocket No.: NICHIA-00700 Shuji Nakamura, et al. January 25, 2000	Serial No.:09/	463643
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CU 4945394 7/3 CV 4946547 8/		el	330	252	3/8/89
CV 4946547 8/	1/90 Nishi	kawa, <i>et al</i> .	156	646	2/28/89
	1/90 Palmo	our, et al.	357	34	10/26/87
CW 4047319 OF	7/90 Palmo	our, et al.	156	643	10/13/89
4947210 8/	7/90 Edmo	ond, et al.	357	13	11/3/87
CX 4959174 9/2	.5/90 Nakaj	jima, et al.	252	301.6R	3/16/89
CY 4960728 10/	/2/90 Schaa	ake, et al.	437	82	10/11/88
CZ 4966862 10/3	30/90 Edmo	ond	437	100	8/28/89
DA 4971739 11/2	20/90 Ichina	ose, et al.	264	61	4/12/89
DB 4977567 12/	11/90 Hank	e	372	45	10/11/89
DC 4982314 1/	1/91 Miki		363	16	12/4/89
DD 4985742 1/1	5/91 Panko	ove	357	34	7/7/89
DE 4987576 1/2	22/91 Heine	en	372	46	11/3/89
DF 4990466 2/3	5/91 Shieh	ı, et al.	437	129	11/1/88
DG 4990990 2/3	5/91 Albre	echt, et al.	357	30	3/23/88
DH 5005057 4/2	2/91 Izumi	iya, et al.	357	17	4/13/90
DI 5006908 4/9	9/91 Matsi	uoka, <i>et al</i> .	357	17	2/12/90
DJ 5008735 4/1	6/91 Edmo	ond, et al.	357	74	12/7/89
DK 5008789 4/1	6/91 Arai,	et al.	362	255	2/14/90
DL 5019746 5/2	28/91 Merg		313	512	12/4/89
DM 5023686 6/1	1/91 Helm	nut, et al.	357	30	6/15/90
DN 5027168 6/2	25/91 Edmo	ond	357	17	8/28/89
DO 5034956 7/2	23/91 Gessr	ner, et al.	372	45	11/2/89
DP 5041334 8/2	0/91 Naka	jima, et al.	428	407	12/19/89
DQ 5042043 8/2	20/91 Hatar	no, et al.	372	45	4/13/90
DR 5045896 9/	3/91 Ash,	et al.	357	17	3/21/89
DS 5049779 9/1	7/91 Itsuki	i, et al.	313	486	4/28/89
DT 5061972 10/2	29/91 Edmo	ond	357	13	9/13/90
DU 5065207 11/	12/91 Heine	en	357	30	2/5/91
DV 5077145 12/	31/91 Shino	omiya, et al.	428	691	12/21/90
DW 5093576 3/A	3/92 Edmo	ond, et al.	250	370.01	3/15/91
DX 5119540 6/	9/92 Kong	g, et al.	29	25.01	7/24/90
DY 5120619 6/	9/92 Naka	jima, et al.	428	690	11/7/90
DZ 5122845 6/1	6/92 Mana	abe, et al.	357	17	2/26/90
15WB EA 5128955 7/	7/9 2 Danie	elmeyer	372	94	8/18/88
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FORM PTO-1449

(Modified)

U.S. Department of Commerce Patent and Trademark Office

Attorney Docket No.: NICHIA-00700

Serial No.:09/463643

Applicant: Shuji Nakamura, et al.

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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CFR § 1.9	FR § 1.98(b))			Filing Date: January 25, 2000		Group Art Unit:		
WB	EB	5146465	9/8/92	Khan, et al.		372	45	2/1/91
1	EC	5155062	10/13/92	Coleman	·	437	100	12/20/90
†	ED	5171370	12/15/92	Reithmaier, et al.		118	726	4/18/90
1	EE	5182670	1/26/93	Khan, et al.		359	359	8/30/91
1	EF	5184247	2/2/93	Schimpe		359	344	7/17/90
	EG	5185207	2/9/93	Furuoka, et al.		428	404	12/27/91
	EH	5200022	4/6/93	Kong, et al.		156	612	10/3/90
	EI	5202777	4/13/93	Sluzky, et al.		359	50	4/1/92
1	EJ	5205905	4/27/93	Kotaki, et al.		156	662	5/30/91
	EK	5208878	5/4/93	Thulke		385	14	10/2/91
	EL	5210051	5/11/93	Carter, Jr.		437	107	6/5/91
	EM	5218216	6/8/93	Manabe, et al.		257	103	12/20/91
	EN	5229626	7/20/93	Ebitani, et al.		257	84	3/27/92
	EO	5233204	8/3/93	Fletcher, et al.		257	13	1/10/92
	EP	5239188	8/24/93	Takeuchi, et al.		257	76	11/4/92
	EQ	5247533	9/21/93	Okazaki, et al.		372	45	12/26/91
	ER	5250366	10/5/93	Nakajima, et al.		428	690	5/8/92
	ES	5252499	10/12/93	Rothschild		437	22	8/15/88
	ET	5252839	10/12/93	Fouquet		257	13	6/10/92
	EU	5260960	11/9/93	Amann, et al.		372	46	4/23/92
	EV	5264713	11/23/93	Palmour		257	77	6/14/91
	EW	5266503	11/30/93	Wang, et al.		437	24	10/2/91
	EX	5270554	12/14/93	Palmour		257	77	6/14/91
	EY	5272108	12/21/93	Kozawa		437	127	2/26/92
	EZ	5278433	1/11/94	Manabe, et al.		257	103	8/7/92
	FA	5281830	1/25/94	Kotaki, et al.		257	86	10/24/91
	FB	5290393	3/1/94	Nakamura		156	613	1/28/92
	FC	5306662	4/26/94	Nakamura, et al.		437	107	11/2/92
	FD	5312560	5/17/94	Somatomo, et al.	•	252	301.4 S	3/18/93
	FE	5323022	6/21/94	Glass, et al.		257	77	9/10/92
	FF	5330791	7/19/94	Aihara, et al.		427	215	4/16/93
	FG	5334277	8/2/94	Nakamura	·	117	102	10/22/91
	FH	5336080	8/9/94	Sumitomo, et al.		428	407	12/17/92
	FI	5338944	8/16/94	Edmond, et al.		257	76	9/22/93
	FJ	5341390	8/23/94	Yamada, et al.		372	45	4/15/93
3WB	FK	5343316	8/30/94	Morimoto, et al.		359	50	6/29/93

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U.S. Department of Commerce Patent and Trademark Office

Attorney Docket No.: NICHIA-00700

Serial No.:09/463643

Applicant: Shuji Nakamura, et al.

Filing Date: January 25, 2000

Group Art Unit:

WB	FL	5344791	9/6/94	Huang	 437	126	8/14/92
· · · ·	FM	5359345	10/25/94	Hunter	345	102	8/5/92
1	FN	5363390	11/8/94	Yang, et al.	372	22	11/22/93
+-	FO	5366834	11/22/94	Yoneda, et al.	 430	23	5/5/93
1	FP	5369289	11/29/94	Tamaki, et al.	257	99	10/30/92
1	FQ	5376303	12/27/94	Royce, et al.	252	301.4 R	1/10/94
	FR	5376580	12/27/94	Kish, et al.	437	127	3/19/93
-	FS	5381103	1/10/95	Edmond, et al.	324	753	10/13/92
	FT	5382822	1/17/95	Stein	257	410	9/27/93
_	FU	5389571	2/14/95	Takeuchi, et al.	437	133	4/16/93
	FV	5390210	2/14/95	Fouquet, et al.	372	92	11/22/93
_ _	FW	5393993	2/28/95	Edmond, et al.	257	77	12/13/93
	FX	5394005	2/28/95	Brown, et al.	257	461	2/18/94
\top	FY	5403774	4/4/95	Shieh, et al.	437	129	11/6/92
	FZ	5404282	4/4/95	Klinke, et al.	 362	249	8/19/94
	GA	5408120	4/18/95	Manabe, et al.	257	431	1/22/93
	GB	5409859	4/25/95	Glass, et al.	437	187	4/22/94
	GC	5416342	5/16/95	Edmond, et al.	 257	76	6/23/93
-	GD	5417886	5/23/95	Tateiwa, et al.	252	301.4 R	9/20/93
	GE	5433169	7/18/95	Nakamura	117	102	4/6/94
	GF	5433533	7/18/95	Imazaike	384	488	12/20/93
	GG	5433888	7/18/95	Okada, et al.	252	301.4 R	9/20/93
	GH	5435938	7/25/95	Bando, et al.	 252	301.4 S	3/10/94
	GI	5438198	8/1/95	Ebitani, et al.	250	330	5/3/94
	GJ	5459107	10/17/95	Palmour	437	238	6/5/92
	GK	5465249	11/7/95	Cooper, Jr. et al.	365	149	11/26/91
	GL	5467291	11/14/95	Fan, et al.	364	578	12/5/91
	GM	5468678	11/21/95	Nakamura, et al.	 437	107	1/12/94
	GN	5475241	12/12/95	Harrah, et al.	257	99	10/27/93
	GO	5497012	3/5/96	Moli	257	183	6/15/94
	GP	5502316	3/26/96	Kish, et al.	257	94	10/12/95
	GΩ	5506421	4/9/96	Palmour	257	77	11/24/92
	GR	5511084	4/23/96	Amann	372	20	1/17/95
	GS	5514627	5/7/96	Lowery, et al.	 437	209	1/24/94
	GT	5523018	6/4/96	Okada, et al.	252	301.4 P	3/23/95
BrM	GU	5523589	6/4/96	Edmond, et al.	 257	77	9/20/94

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communication to applicant.

Sheet 6 of 11 MAY 2 2 2000 Attorney Docket No.: NICHIA-00700 Serial No.:09/463643 FORM PTO-1449 U.S. Department of Commerce Patent and Trademark Office (Modified) Applicant: Shuji Nakamura, et al. INFORMATION DISCLOSURE STATEMENT BY APPLICANT Group Art Unit: Filing Date: January 25, 2000 (37 CFR § 1.98(b)) 257 8/9/93 7/23/96 Edmond, et al. 77 5539217 GW 10/8/96 257 13 4/28/94 5563422 Nakamura, et al. 257 11/17/93 GΧ 96 5578839 11/26/96 Nakamura, et al. 4/19/95 GY 5583879 12/10/96 Yamazaki, et al. 372 45 257 77 2/3/95 GΖ 12/17/96 Tischler 5585648 НΑ 257 94 4/19/95 5587593 12/24/96 Koide, et al. ΗВ 372 45 9/20/94 5592501 1/7/97 Edmond, et al. 11/1/95 HC 1/7/97 Ruh 385 31 5592578 96 6/8/95 HD 5596595 1/21/97 Tan, et al. 372 437 22 8/12/94 ΗE 2/18/97 5604135 Edmond, et al. HF 372 4/19/95 45 5604763 2/18/97 Kato, et al. HG Palmour 437 238 12/9/94 5612260 3/18/97 НН 9/25/95 3/25/97 Neumann, et al. 257 102 5614736 ΗI 117 102 2/22/95 4/1/97 5616177 Yamada 6/26/95 НJ 438 507 5620557 4/15/97 Manabe, et al. 9/6/95 HK 4/15/97 372 69 5621749 Baney $^{\rm HL}$ 4/29/97 Chai 257 94 6/8/95 5625202 НМ 526 92 4/26/95 5/6/97 Sato 5627244 257 77 12/9/94 HN 5629531 5/13/97 Palmour 33 10/7/94 НО 438 5631190 5/20/97 Negley 423 65 11/30/95 ΗP 6/3/97 Singh, et al. 5635146 97 НQ 372 10/26/95 5642375 6/24/97 King, et al. 88 8/31/95 HR 257 5650641 7/22/97 Sassa, et al. 257 6/17/96 HS 5652434 7/29/97 Nakamura, et al. 13 ΗT 257 94 7/19/95 7/29/97 Sassa, et al. 5652438 3/8/95 HU 257 190 5656832 8/12/97 Ohba, et al. 372 5/23/95 ΗV Wang, et al. 96 5659568 8/19/97 5/24/95 438 HW 5661074 8/26/97 Tischler 32 190 9/20/96 HX 257 5661316 8/26/97 Kish, Jr., et al. ΗY 8/26/97 372 46 5/22/96 5661742 Huang, et al. ΗZ 257 96 3/29/95 5670798 9/23/97 Schetzina 11/30/94 ΙA 117 106 5679153 10/21/97 Dmitriev, et al. 359 346 11/21/96 ΙB 11/4/97 5684623 King, et al. IC 257 77 9/16/94 5686737 11/11/97 Allen ID 129 3/20/95 5700713 12/23/97 Yamazaki, et al. 437 ΙE 362 231 11/1/95 5707139 1/13/98 Haitz Date Considered: ט' Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next EXAMINER: communication to applicant.

ه بيت افتعادي , Sheet 7 of 11 MAY 2 2 2000 Attorney Docket No.: NICHIA-00700 FORM PTO-1449 U.S. Department of Commerce Serial No.:09/463643 (Modified) Patent and Trademark Office Applicant: Shuji Nakamura, et al. INFORMATION DESCRIPTION STATEMENT BY APPLICANT Group Art Unit: Filing Date: January 25, 2000 (37 CFR § 1.98(b)) 117 2/5/96 5718760 2/17/98 Carter, et al. 84 257 IG 77 6/6/96 5719409 2/17/98 Singh, et al. ΙH 3/3/98 Hunter 345 102 9/21/94 5724062 ΙI Chang 372 20 11/15/96 5724373 3/3/98 IJ 372 96 11/30/95 3/3/98 5724376 Kish, Jr., et al. IK 5727014 3/10/98 Wang, et al. 372 96 10/31/95 IL3/17/98 257 13 9/6/96 5729029 Rudaz IM 372 5729567 3/17/98 Nakagawa 99 4/25/96 IN 437 127 11/9/95 3/31/98 5733796 Manabe, et al. 6/10/96 IO 257 5734182 3/31/98 Nakamura, et al. 96 ΙP 5739552 4/14/98 Kimura, et al. 257 89 10/24/95 ΙQ 103 5/8/95 5739554 4/14/98 257 Edmond, et al. IR 216 65 5/15/97 5741431 4/21/98 Shih IS 437 128 12/27/96 5741724 4/21/98 Ramdani, et al. IT 4/21/98 315 291 9/9/96 5742133 Wilhelm, et al. ΙU 6/10/96 5747832 5/5/98 Nakamura, et al. 257 103 ΙV 257 3/7/97 94 5753939 5/19/98 Sassa, et al. IW 362 259 6/27/97 5758951 6/2/98 Haitz IX 372 31 1/25/96 5761229 6/2/98 Baldwin, et al. ΙY 6/17/96 5767581 Nakamura, et al. 257 749 6/16/98 ΙZ 372 31 6/3/96 5771254 6/23/98 Baldwin, et al. JA 438 767 11/19/96 5776837 7/7/98 Palmour 11/30/95 JB 7/7/98 257 96 5777350 Nakamura, et al. JC 5777433 7/7/98 313 512 7/11/96 Lester, et al. JD 216 24 3/22/96 5779924 7/14/98 Krames, et al. JΕ 427 554 12/18/96 5780120 7/14/98 Belouet, et al. JF 6/29/95 5785404 7/28/98 Wiese 362 32 JG 257 18 6/13/96 5793054 8/11/98 Nido JH 5793062 8/11/98 Kish, Jr., et al. 257 98 10/24/97 JΙ 372 45 7/30/96 5805624 9/8/98 Yang, et al. JJ 257 88 3/29/96 5808323 9/15/98 Spaeth, et al. JK 345 83 4/21/95 5808592 9/15/98 Mizutani, et al. JL 372 43 1/25/96 5809050 9/15/98 Baldwin, et al. JM 438 46 3/26/96 5811319 9/22/98 Koike, et al. JN 313 512 3/4/96 9/22/98 Mueller-Mach, et al. 5811931 ちゅじ JO 345 83 6/10/96 Van De Ven 5812105 9/22/98 Date Considered: 0 Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next EXAMINER: communication to applicant.

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	B	JP	5812570	9/22/98	Spaeth		372	36	9/30/96
 	<u>Ų</u>	JQ	5814870	9/29/98	Spaeth		257	433	1/6/97
f		JR	5818861	10/6/98	Tan, et al.		372	46	7/19/96
		JS	5828684	10/27/98	Van De Walle		372	45	12/29/95
		JT	5831288	11/3/98	Singh, et al.		257	77	9/29/97
<u> </u>		JU	5835514	11/10/98	Yuen, et al.		372	36	1/25/96
		JV	5835522	11/10/98	King, et al.		372	97	11/19/96
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		JX	5838706	11/17/98	Edmond, et al.		372	45	11/19/96
		JY	5838707	11/17/98	Ramdani, et al.		372	45	12/27/96
		JZ	5838708	11/17/98	Lin, et al.		372	50	8/1/95
		KA	5846844	12/8/98	Akasaki, et al.		437	21	2/7/96
		КВ	5847507	12/8/98	Butterworth, et al.		313	512	7/14/97
	-	KC	5850410	12/15/98	Kuramata		372	43	3/18/96
		KD	5855924	1/5/99	Lumbard		425	116	12/27/95
		KE	5858277	1/12/99	Chau, et al.		252	301.4 F	12/23/92
		KF	5859496	1/12/99	Murazaki, et al.		313	485	5/10/96
		KG	5861190	1/19/99	Greene, et al.		427	248.1	3/25/96
		КН	5861713	1/19/99	Kondo, et al.		313	495	6/26/97
		кі	5862167	1/19/99	Sassa, et al.		372	45	5/27/97
		кј	5867516	2/2/99	Corzine, et al.		372	45	3/12/96
1		KK	5868837	2/9/99	Disalvo, et al.		117	952	1/13/98
		KL	5877558	3/2/99	Nakamura, et al.		257	749	12/19/97
	T	KM	5879587	3/9/99	Yale		252	301.45	9/24/97
		KN	5879588	3/9/99	Yale		252	301.45	9/24/97
		ко	5880486	3/9/99	Nakamura, et al.		257	96	8/30/96
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		KS	5892787	4/6/99	Tan, et al.		372	96	4/22/96
		KT	5900650	5/4/99	Nitta		257	94	7/2/97
		KU	5905276	5/18/99	Manabe, et al.		257	103	11/6/97
		KV	5907151	5/25/99	Gramann, et al.		250	214.1	5/27/97
	\perp	KW	5912477	6/15/99	Negley		257	95	5/20/97
		KX	5917202	6/29/99	Haitz, et al.		257	98	12/21/95
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)	-	LA	5923053	7/13/99	Jakowetz, et al.		257	95	9/30/96
		LB	5923118	6/13/99	Jennato, et al.		313	485	3/7/97
		LC	5923690	7/13/99	Kume, et al.		372	46	1/24/97
		LD	5923946	7/13/99	Negley		438	4	4/17/97
		LE	5925898	7/20/99	Spath		257	98	1/26/98
		LF	5927995	7/27/99	Chen, et al.		438	517	4/9/97
		LG	5935705	8/10/99	Chen, et al.	<u> </u>	428	367	10/15/97
		LH	5936985	8/10/99	Yamamoto, et al.		372	38	9/13/95
		LI	5945689	8/31/99	Koike, et al.		257	88	3/18/96
		LJ	5953361	9/14/99	Borchert, et al.		372	96	11/25/97
		LK	5953581	9/14/99	Yamasaki, et al.		438	22	4/17/97
		LL	5958295	9/28/99	Yale		252	301.4 S	9/24/97
		LM	5959316	9/28/99	Lowery		257	98	9/1/98
		LN	5959401	9/28/99	Asami, et al.		313	503	5/21/97
		LO	5961723	10/5/99	Roithner, et al.		118	715	11/26/96
		LP	5964943	10/12/99	Stein, et al.		117	88	6/25/97
		LQ	5966393	10/12/99	Hide, et al.		372	23	2/4/97
		LR	5968265	10/19/99	Stein, et al.		117	71	1/27/98
		LS	5969378	10/19/99	Singh		257	77	7/10/97
		LT	5972781	10/26/99	Wegleiter, et al.		438	460	9/30/97
		LU	5972801	10/26/99	Lipkin, et al.		438	770	11/8/95
		ΓΛ	5973336	10/26/99	Hanke, et al.		257	94	11/3/97
		LW	5980631	11/9/99	Tews, et al.		117	89	12/17/97
		LX	5981945	11/9/99	Spaeth, et al.		250	239	3/8/96
	1 1	LY	5981979	11/9/99	Brunner		257	99	11/26/97
	1	LZ	5982970	11/9/99	Schneider		385	125	9/19/97
		MA	5986317	11/16/99	Wiese		257	433	9/29/95
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		MC	5994722	11/30/99	Averbeck, et al.		257	89	6/30/98
		MD	5998925	12/7/99	Shimizu, et al.		313	503	7/29/97
		ME	5999552	12/7/99	Bogner, et al.		372	43	1/20/98
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	MJ	EP0380340A2	8/1/90	EP		HO1L	29/91	
	MK	EP0380340A3	8/1/90	EP		H01L	29/91	
	ML	EP0637069A1	2/1/95	EP		HO1L	21/473	
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	MN	EP0731512A3	7/2/97	EP		H01L	33/00	
	MO	EP0781619A1	7/2/97	EP		B23H	7/02	
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	MQ	EP0871208A3	12/16/98	EP		H01L	21/20	
	MR	EP0880181A2	11/25/98	EP		HOIL	29/45	
	MS	EP0880181A3	1/20/99	EP	–	H01L	29/45	
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	NA	JP09193137	7/29/97	JP V		B28D	5/014	
	NB.	JP10233529	2/14/97	JP		HOIL	33/00	
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- [NF	WO9702610A1	1/23/97	PCT		H01L	31/173	, ,
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	NK	WO9805078A1	2/5/98	PCT		HO1L	33/00	
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	NV	WO9918617A1	4/15/99	PCT		HO1L	33/00		
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Sheet 1 of 1 U.S. Department of Commerce FORM PTO-1449 Attorney Docket No.: NICHIA-00700 Serial No.: 09/463,643 (Modified) * Patent and Trademark Office INFORMATION DISCLOSING TEMENT BY APPLICANT Applicant: Shuji Nakamura et al. (Use Several Sheets If Necessary) Group Art Unit: Filing Date: January 25, 2000 (37 CFR § 1.98(b)) FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS Translation Document Country / Patent Office Class Subclass Publication Date Number Yes No AA 04144294 5/18/92 JP H01S 3/18 Х ΑB 09180998 7/11/97 JP H01L 21/20 Х Х 09246651 9/19/97 JP H01S 3/18 ACΑD 09260772 10/3/97 JP H01S 3/18 X ΑE 09293935 11/11/97 JP H01S 3/18 Х 9/11/98 JP H01S 3/18 Х ΑF 10242565 H01S 3/18 Х AG 10256645 9/25/98 JP 10270792 10/9/98 H01S 3/18 Х AΗ JP 10290027 10/27/98 JP H01L 33/00 Х ΑI 3/18 Х JP H01S AM 10294529 11/4/98 ΑN 10321962 12/4/98 JP H01S 3/18 Х JР 3/18 Х 11040893 2/12/99 H01S ΑN 5/30 X, HOIS 2000-31599 1/28/00 DE 196 48 TRANSLATI $\overline{\mathbf{x}}$ HOIL 33/00 5/28/97 DE 955A1 ÀΌ OTHER DOCUMENTS (Including Author, Title, Date, Relevant Pages, Place of Publication) "InGaN/GaN/AIGaN-based laser diodes with modulation-doped strained-layer superlattices grown on an epitaxially laterally overgrown GaN substrate," Shuji Nakamura et al., Applied Physics Letter, Vol. 72, No. 2, January 12, 1998. AR AS ΑT ΑU ΑV ΑW ΑX ΑY ΑZ

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